Attorney Docket: 30205/37328 Inventors: Min Ho Jung et al.

Title: "Additive for Photoresist Composition for Resist Flow Process" Sheet 1 of 2



Fig.1

Attorney Docket: 30205/37328 Inventors: Min Ho Jung et al. Title: "Additive for Photoresist Composition for Resist Flow Process" Sheet 2 of 2



Fig.2